



Patent
Attorney's Docket No. 003510-120

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Tomotaka TSUCHMURA et al.

Application No.: 10/077,943

Filed: February 20, 2002

For: POSITIVE-TYPE IMAGE-FORMING
MATERIAL AND PLANOGRAPHIC
PRINTING PLATE PRECURSOR

} Group Art Unit: 1752

} Examiner: (unassigned)

} Confirmation No.: 4990

#4

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**INFORMATION DISCLOSURE STATEMENT
TRANSMITTAL LETTER**

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

Enclosed is an Information Disclosure Statement and accompanying form PTO-1449 for the above-identified patent application.

- No additional fee for submission of an IDS is required.
- The fee of \$180.00 (1806) as set forth in 37 C.F.R. § 1.17(p) is also enclosed.
- A statement under 37 C.F.R. § 1.97(e) is also enclosed.
- A statement under 37 C.F.R. § 1.97(e), and the fee of \$180.00 (1806) as set forth in 37 C.F.R. § 1.17(p) are also enclosed.
- Charge \$_____ to Deposit Account No. 02-4800 for the fee due.
- A check in the amount of \$_____ is enclosed for the fee due.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

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Substitute for form 1449A/PTO

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

ATTORNEY'S DKT No.
003510-120

APPLICATION NO.
10/77,943

APPLICANT
Tomotaka TSUCHIMURA et al.

FILING DATE	GROUP
February 20, 2002	1752

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. SEND TO: Assistant Commissioner for Patents, Washington, D.C. 20231.